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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/695,642	10/29/2003	Naoya Sashida	032061	5390
38834 7	590 07/11/2005		EXAM	INER
WESTERMAN, HATTORI, DANIELS & ADRIAN, LLP			PHAM, THANHHA S	
1250 CONNECTICUT AVENUE, NW SUITE 700		ART UNIT	PAPER NUMBER	
WASHINGTON, DC 20036			2813	

DATE MAILED: 07/11/2005

Please find below and/or attached an Office communication concerning this application or proceeding.

	Application No.	Applicant(s)				
	10/695,642	SASHIDA ET AL.				
Office Action Summary	Examiner	Art Unit				
	Thanhha Pham	2813				
The MAILING DATE of this communication appears on the cover sheet with the correspondence address Period for Reply						
A SHORTENED STATUTORY PERIOD FOR REPLY THE MAILING DATE OF THIS COMMUNICATION. - Extensions of time may be available under the provisions of 37 CFR 1.13 - after SIX (6) MONTHS from the mailing date of this communication. - If the period for reply specified above is less than thirty (30) days, a reply If NO period for reply is specified above, the maximum statutory period w - Failure to reply within the set or extended period for reply will, by statute, Any reply received by the Office later than three months after the mailing earned patent term adjustment. See 37 CFR 1.704(b).	36(a). In no event, however, may a reply be time within the statutory minimum of thirty (30) days will apply and will expire SIX (6) MONTHS from cause the application to become ABANDONE	nely filed s will be considered timely. the mailing date of this communication. O (35 U.S.C. § 133).				
Status						
1)⊠ Responsive to communication(s) filed on <u>14 April 2005</u> .						
2a) ☐ This action is FINAL . 2b) ☒ This	action is non-final.					
	Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under <i>Ex parte Quayle</i> , 1935 C.D. 11, 453 O.G. 213.					
Disposition of Claims						
 4) Claim(s) 1-21 is/are pending in the application. 4a) Of the above claim(s) 12-14 and 16-21 is/are withdrawn from consideration. 5) Claim(s) is/are allowed. 6) Claim(s) 1-11 is/are rejected. 7) Claim(s) 15 is/are objected to. 8) Claim(s) are subject to restriction and/or election requirement. 						
Application Papers						
9) The specification is objected to by the Examiner. 10) The drawing(s) filed on is/are: a) accepted or b) objected to by the Examiner.						
Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).						
Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d). 11) The oath or declaration is objected to by the Examiner. Note the attached Office Action or form PTO-152.						
Priority under 35 U.S.C. § 119						
 12) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f). a) All b) Some * c) None of: 1. Certified copies of the priority documents have been received. 2. Certified copies of the priority documents have been received in Application No 3. Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)). * See the attached detailed Office action for a list of the certified copies not received. 						
Attachment(s)	. 🗖					
1) Notice of References Cited (PTO-892) 4) Interview Summary (PTO-413) 2) Notice of Draftsperson's Patent Drawing Review (PTO-948) Paper No(s)/Mail Date						
Notice of Information Disclosure Statement(s) (PTO-1449 or PTO/SB/08) Notice of Informal Patent Application (PTO-152) Paper No(s)/Mail Date 01/05/2004. 5) Other:						

DETAILED ACTION

This Office Action is in response to Applicant Response to Election of Species Requirement dated 04/14/2005.

Election/Restrictions

- 1. Applicant's election of Species A (figs 1A-1R) in the reply filed on 04/14/2005 is acknowledged. Because applicant did not distinctly and specifically point out the supposed errors in the restriction requirement, the election has been treated as an election without traverse (MPEP § 818.03(a)).
- 2. Applicant's election to claims 1-11 and 15-21 read on species A of figure 1A-1R is acknowledged. However, there is an error to the election since claims 16-21 depend on claim 14 of species D of figures 27A-27I, not species A. Claims 16-21 should be also withdrawn from consideration since they belong to a different species.
- 3. Accordingly, claims 12-14 and 16-21 are withdrawn from further consideration pursuant to 37 CFR 1.142(b) as being drawn to nonelected species.

Claim Rejections - 35 USC § 112

The following is a quotation of the second paragraph of 35 U.S.C. 112:

The specification shall conclude with one or more claims particularly pointing out and distinctly claiming the subject matter which the applicant regards as his invention.

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4. Claim 6 is rejected under 35 U.S.C. 112, second paragraph, as being

indefinite for failing to particularly point out and distinctly claim the subject

matter which applicant regards as the invention.

▶ With respect to claim 6, it is not clear how removal of a moisture can be executed

by coating alcohol on the first conductive film when a surface of the insulating film is

dehydrated after the plasma is irradiated onto the insulating film and before the self-

orientation layer is formed – notice that the film conductive film is formed after the

self-orientation layer is formed.

Claim Rejections - 35 USC § 102

The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

(b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.

- 5. Claims 1-2 are 7-11 rejected under 35 U.S.C. 102(b) as being anticipated by Sekiguchi [US 2002/0024142].
- ► With respect to claims 1-2 and 7-9, Sekiguchi (figs 5's-6's and text [0001]-[0161]) discloses the claimed manufacturing method of a semiconductor device comprising steps of:

forming an insulating film (501, fig 5A, text [0133]) over a semiconductor substrate (500) [claim 1];

exciting a plasma of a gas having a molecular structure in which hydrogen and nitrogen are bonded and irradiating the plasma onto the insulating film wherein the gas is an ammonia gas (text [0158]) [claims 1 and 2];

forming a self-orientation layer made of substance having a self-orientation characteristic (503, copper, fig 5A, text [0133], [0156]-[0157]) on the insulating film, wherein the self-orientation layer is formed of any one of titanium, aluminum, silicon, copper, tantalum, tantalum nitride, iridium, iridium oxide, and platinum, [claims 1 and 7]; and

forming a first conductive film (504, copper, fig 5A, text [0135], [0156]-[0157]) made of conductive substance having the self-orientation characteristic on the self-orientation layer, wherein the first conductive film is formed of any one of titanium, aluminum, silicon, copper, tantalum, tantalum nitride, iridium, iridium oxide, and platinum, wherein the first conductive film is formed by any one of a sputter method, a plasma CVD method, an MOCVD method, and a plating method [claims 1, 8 and 9]

▶ With respect to claims 10-11, Sekiguchi (figs 5B-5C) shows forming a conductive pattern by patterning the first conductive film and the self-orientation layer wherein the conductive pattern is any one of an electrode and a wiring.

Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the

invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

6. Claims 3-4 are rejected under 35 U.S.C. 103(a) as being unpatentable over Sekiguchi [US 2002/0024142] in view of Abe [US 2002/0013057].

Sekiguchi substantially discloses the claimed method including after the plasma is irradiated into the insulating film, the self-orientation layer (503, copper) is formed on the insulating film. Sekiguchi does not specifically mention forming said self-orientation layer while maintain a state that the insulating film is put in a vacuum atmosphere wherein a pressure of vacuum atmosphere is set to 1x10⁻³ torr or less. a vacuum atmosphere with the pressure being set to 1x10⁻³ torr or less

However, forming the self-orientation layer in is known in the art. See Abe (text [0019]-[0020]) as an evidence that shows forming the self-orientation layer in the vacuum atmosphere with the pressure being set to 1x10⁻³ torr or less.

Therefore, at the time of invention, it would have been obvious for those skilled in the art to modify process Sekiguchi by forming the self-orientation layer in vacuum atmosphere as being claimed to prevent contamination to the semiconductor device when forming said film.

Allowable Subject Matter

7. Claim 15 is objected to as being dependent upon a rejected base claim, but would be allowable if rewritten in independent form including all of the limitations of the base claim and any intervening claims.

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8. The following are statements of reasons for the indication of allowable subject matter: Recorded Prior Art fails to disclose or suggest the combination of the process steps as recited in the base claim 1 including forming a ferroelectric film on the first conductive film; forming a second conductive film on the ferroelectric film; forming a capacitor upper electrode by patterning the second conductive film; patterning the ferroelectric film to leave at least under the capacitor upper electrode; and forming the capacitor lower electrode at least below the capacitor upper electrode by patterning the first conductive film and the self-orientation layer as characteristics in claim 15.

Conclusion

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Thanhha Pham whose telephone number is (571) 272-1696. The examiner can normally be reached on Monday and Thursday 9:00AM - 9:30PM.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Carl Whitehead can be reached on (571) 272-1702. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should

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you have questions on access to the Private PAIR system, contact the Electronic

Business Center (EBC) at 866-217-9197 (toll-free).

Thanhha Pham Patent Examiner

Patent Examining Group 2800